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Fluorescence from graphene oxide and the influence of ionic, $\pi - \pi$ interactions and heterointerfaces: electron or energy transfer dynamics

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2D crystals such as graphene and its oxide counterpart have sought good research attention for their application as well as fundamental interest. Especially graphene oxide (GO) is quite interesting because of its versatility and diverse application potential. However the mechanism of fluorescence from GO is under severe discussion. To explain the emission in general two interpretations were suggested, viz localization of sp² clusters and involvement of oxygeneous functional groups. Despite this disagreement, it should be acknowledged that the heterogeneous atomic structure, synthesis dependent and uncontrollable implantation of oxygen functional groups on the basal plane make such explanations more difficult. Nevertheless, a suitable explanation enhances the applicability of the material which also enables the design of novel materials. At this juncture we believe that given the complexity in understanding the emission mechanism it would be very useful to review the literature. In this perspective we juxtapose various results related to fluorescence and influencing factors so that a conclusive interpretation may be unveiled. Apparently, the existing interpretations have largely ignored the factors such as self-rolling, byproduct formation etc. Vis-a-vis previous reviews did not discuss the interfacial charge transfer across heterostructures and the implication on the optical properties of GO or reduced graphene oxide (rGO). Such analysis would be very insightful to determine the energetic location of sub band gap states. Moreover, ionic and $\pi - \pi$ type interactions are also considered for their influence on emission properties. Apart from these, quantum dots, covalent modifications and nonlinear optical properties of GO and rGO were discussed for completeness. Finally we made concluding remarks with outlook.

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1. Introduction

Graphene (Gra) in its pure form has attracted a lot of research attention.^{1,2} Notably its oxidized form, graphene oxide (GO), has also sought equal importance^{2–6} because of its application potential in electronic devices,^{7–9} biomedical and environmental remedies. Initially, in 1860 Brodie¹⁰ produced graphite oxide (presently known as graphene oxide) for the first time and later Staudenmeier¹¹ in 1898 and Hummers *et al.*¹² in 1958 have synthesized the same. Other applications include transparent conductive coatings in pure form^{7,13} to improve the hole transporting property,⁹ flexible optoelectronics¹⁴ and white light fluorophores¹⁵ when combined with potential materials

such as ZnO.¹⁶⁻²² A control on the reduction level enables the band gap tunability²³ while its solution processability to make large area thin films is worth mentioning.²⁴ The band gap tunability permits its application in mid-IR range photodetectors. Furthermore GO is integrated with silicon⁸ which suggests its suitability in industry. On the other hand biomedical applications include cell imaging,²⁵ drug delivery,^{25,26} photothermal therapy and photoacoustic imaging,²⁷ detection of Cu²⁺ ions,²⁸ alcohol sensors,²⁹ biosensors,^{3,30} in vivo toxicology effects³¹ etc. See a review article by Morales-Narvaez et al. for optical bio sensing applications of GO.³⁰ Environmental remedies include photocatalysts^{29,32,33} when combined with semiconductors such as ZnO, ZnS,²⁹ titanosilicate³³ etc. It is notable that the presence of another semiconductor is vital; hence the role of GO or reduced graphene oxide (rGO) is to delay the recombination process in the semiconductor.³² Fig. 1 (top) shows the number of publications against year. We can see the intensity of research in the recent past on GO and related materials. In Fig. 1 (bottom) we have created a tabular form in which the distribution of research areas against the number of publications is given. These data are

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Fig. 1 (top) (a) Number of publications against year and (b) shows the number of articles, reviews and proceedings that have appeared until now. Table (bottom) shows the distribution of research areas against number of publications. Data analyzed from web of knowledge as of 7th July 2014, key word for (a) graphene oxide.

convincing that the research interest in GO is constantly growing given its applicability in a range of research areas.

Fluorescence from graphene should be phonon assisted³⁴ because of its zero band gap. In clear contrast, GO and rGO has shown NIR, visible and UV fluorescence^{15,25,26,35–39} with a quantum efficiency of 6.9%.⁴⁰ Luminescence of GO is also reported in red and NIR regions^{26,38} which can result from the presence of multilayered and aggregated flakes.³⁶ Importantly, the mechanism which describes the fluorescence of GO or rGO is under severe discussion suggesting two different interpretations. One of them is the localization of sp² clusters where the quantum confinement effect splits the energy bands and the recombination of e–h pairs gives luminescence. The second explanation involves O2p orbital where the CB of the localized sp² domains can be assigned to the π^* orbitals, while the VB changes from the π to the O2p orbitals. In the former case, oxygen-related functional

groups are eliminated from the emission mechanism due to the enhancement of fluorescence upon reduction.15,36,39 O2p orbitals are eliminated despite the fact that the method of reduction plays a crucial role in case if the process enhances radiative or non-radiative paths.⁴¹ Interestingly, as mentioned earlier, the band gap of GO is controllable²³ via manipulation of the reduction level. However, rGO is associated with a set of defects such as remnant oxygen atoms,42 pentagon-heptagon pairs (Stone-Wales defects)43,44 and holes44,45 due to the loss of carbon from the basal plane.⁴⁶ Especially with the chemical reduction, hydrazine is found to be efficient in removing in plane functional groups (epoxy and hydroxyl), however, the edge moieties (carboxyl and carbonyl) stay undisturbed.⁴⁷⁻⁴⁹ In addition, it is also found that hydrazine reduction creates new functional groups such as C=N on the rGO.⁵⁰⁻⁵³ To emphasize, it is vital to elucidate a suitable mechanism for the luminescence of GO and rGO. This should be able to explain the influence of various factors such as the reduction level against luminescence properties. An appropriate mechanism allows us to design new material combinations where GO and rGO can be further exploited.

In the present perspective we have avoided the GO-synthesis details, however, please refer to an earlier article in which various chemical methods are discussed in the view point of large-area thin-film electronics and optoelectronics.5 Structural, electronic, optical and vibrational properties of nanoscale carbons and nanowires are discussed in a review by Cole et al.4 Graphenebased nanomaterials in optical and optoelectronic applications were reviewed by Chang et al.54 Given the background and disagreements in interpreting the emission mechanism necessitates its understanding of the current state of art. Hence in this perspective we critically discuss various results from the literature in an attempt to provide a clear insight into those explanations. We also cover the role of prominent functional groups and the tunable band gap, the excitation dependent emission process, quantum dots (QDs), the doping-effect on the emission properties, nonlinear optical properties and the influence of noncovalent/covalent functionalization. Given the contextual nature, we have briefly discussed various reduction processes and their effects as well. We will see that during the reduction process removal of oxygen is as inevitable as the formation of other complex bonds. Furthermore we have discussed ionic interactions such as pH dependency and interaction with other ionic species including the π - π type. Finally, heterointerfaces and the consequent charge transfer mechanism are discussed in relation to photovoltaics and nanocomposites.

2. Reduction of graphene oxide

In the context of applications a scalable method is demanding to produce potential materials such as GO or rGO. The excellent properties depicted by these materials require mass production within the lines of well established and industrially applicable procedures. Gra in its oxidized form is less conducting (of course depending on the level of oxidation) because of the distorted conjugation. It is important that we meet the above mentioned criteria of scalability and conductivity. In this context one of the

ways forward is the reduction of exfoliated GO. We can retrieve the electrical properties of GO to an extent by chemical and thermal reductions.35 To date, the rGO sheets reduced by hydriodic acid and acetic acid have shown the best electronic conductivity (up to 30 000 S m⁻¹).⁵⁵ The 'retrieval of conductivity' is not the main objective of this section. Nevertheless the methods discussed here are in fact correlated with the emission properties. For example, in a molecular dynamics simulation the formation of highly stable carbonyl and ether groups is inevitable in a thermal reduction process.⁵⁶ Hence the optical properties depicted by thermally reduced GO should consider the presence/ formation of these functional groups and the associated influence on the emission properties. In the following we have mentioned some of the techniques such as thermal,^{35,57} photo-thermal⁵⁸ and chemical^{6,35,59} reductions. Various other reducing agents and techniques can be seen from ref. 5. For the following reagents, see the cross references in the given citation. Ammonia, NaBH₄, supercritical water, sugar and ascorbic acid;⁶⁰ bovine serum albumin, bacterial respiration and hydriodic acid;⁶¹ hydroquinone, strong alkaline media, sulfur-containing compounds and amines;62 electrochemical and photographic camera flash.63 Reduction in principle decreases the density of oxygeneous functional groups, while the selectivity is of course process dependent. The presence of residual oxygen-containing functional groups and defects are detrimental for various applications. These active sites make the surface reactive and provide the tunability in electronic and optoelectronic properties via chemical reactions, 36,43,64 including their incorporation in nanocomposites.⁶⁵

When compared to hydrazine, hydriodic acid is less toxic and may be employed for the mass production of rGO. Controlled ozone treatment can tune the electrical and optical properties of graphene⁶⁶ *via* oxidation. Thermal reduction is another versatile and industrially applicable process to reduce GO.³⁵ Low temperature thermal reduction is implemented on large area self assembled GO films.⁵⁷ Furthermore, in photothermal reduction UV light impinges on the samples which are simultaneously subjected to heating. This is a quite interesting method where a precise control of the reduction level can be obtained,⁵⁸ especially in the lab scale environment for synthesizing novel derivatives of GO.

In the context of chemical reduction, hydrazine and its derivatives are rather potential reducing agents which were extensively studied in the literature.³⁵ The important consequences of employing hydrazine in vapor or liquid phase are discussed in Section 3.2. To draw readers' attention to one of the key features, a study by Mathkar *et al.*⁵⁹ shows the band gap tunability by simply varying the exposure time of hydrazine vapor (will be discussed, Fig. 5). Oxygen plasma treatment is a better method in some aspects when compared to that of hydrazine. The oxygen plasma treatment creates much cleaner rGO⁶⁷ while converting the epoxy groups into carbonyl groups though limited to the surface for a multilayered sample. Interestingly, oxygen plasma treatment can convert non-emitting graphene into a broad red-NIR emitting layer⁶⁸ with spatial uniformity. While hydrazine treatment is prone to create C—N bonds.^{50,53}

3. Emission properties of GO

3.1 Fluorescence of luminescence?

Several authors refer the emission from GO as photoluminescence (PL). However, given the time scales of the decay process it would be appropriate to refer the emission as fluorescence (PL occurs in the order of ps). For example, lifetimes are below 6 ns for multicolour fluorescent GO which is synthesized by cleaving CNT upon oxidation.⁶⁹ Some examples of decay times for various combinations of GO or rGO with other materials are tabulated in Table 1. Also the details of excitation and emission wavelengths were given where available. From the table, it is clear that the decay times are in the order of nanoseconds. Nevertheless it is notable that the total decay curve might an integral of more than one decay process.⁷⁰ It is important to note that the number of components is determined by the chemistry of the material and the relative stability of the intermediate states. A better understanding of the emission

Table 1 Decay times for various combinations of GO or rGO and the mechanism if attributed

		Excitation	Emission	Decay time (ns)				
S. no	Compound	$\lambda_{\rm ex} (\rm nm)$	$\lambda_{\rm em} (\rm nm)$	τ_1	τ_2	τ_3	Mechanism/comment	Ref.
1	GO from cleaved CNT	365	38-690	5.1			Localized sp ² clusters	69
2	rGO	318	All	5	1.2	0.2	π - π type noncovalent attachment	70
	Rb	375	400-700	4.76				
	rGO–Rb noncovalent	358	440					
	362	460						
3	GO QDs	NA	NA	~ 5.4				28
	GO QDs/Cu ²⁺	NA	NA	~ 5.4			Complexation (static quenching)	
4	\mathbf{P}^+	438^{a}	640	~ 20				91
	$\mathrm{GO/P}^+$	438 ^{<i>a</i>}	640	1.2	6		e^- and/or energy transfer from P^+ to GO, donor acceptor complex	
	P^{-}	438^a	640	$12 < \tau_1 < 20^b$			1 1	
	GO/P^{-}	438^a	640	-			No interaction: repulsion between similar charges	
5	P3HT	400^{c}	575	0.748			Covalent bonding: π - π interaction dynamic quenching	92
	GO/P3HT	400^{c}	575	0.532			and forming a non-fluorescent ground-state complex	
	rGO/P3HT	400^{c}	575	0.351			Charge pairs are injected into GO as fast as 1.4 ps	

^a 250 ps pulse width. ^b Approximated from the graph as the actual value was not given. ^c ~46 nJ cm⁻².

properties can perhaps suggest an appropriate number of decay constants.

3.2 Mechanism of fluorescence

If fluorescence has to occur in Gr then it must be assisted by phonons³⁴ because of its zero band gap. While in the case of GO and rGO with heterogeneous atomic and electronic structures depicted UV, visible and NIR fluorescence.^{6,15,25,26,35-39} On the other hand, UV-Vis emission from carbon based materials (amorphous,⁷¹⁻⁷³ disordered carbons⁷⁴⁻⁷⁶) is known. However, band gap tunability and solution processability of GO enables its versatility in various applications.⁶ Previously (Section 3.1, Table 1) we have broadly seen the emission wavelengths and their decay times of GO and rGO in pure form or when attached to other functional materials via covalent or noncovalent means. Note that as-synthesized GO did not emit light at all instances.^{37,77} On the other hand emission at specific wavelengths, for example, 440 nm,¹⁵ 505 nm³¹ and the blue-UV region,^{15,36,39} was observed. The emission wavelengths of GO depend on the functional groups,⁴⁵ pH^{69,78-82} and its combination with other materials such as PANI-nanorods,⁸³ MB,⁸⁴ tetra-amino porphyrin,⁸⁵ PEG^{25,26} etc. Since the emission from GO is dependent on various factors, one should go deeper to understand the mechanism. Strong heterogeneity in the atomic and electronic structure makes the emission process quite complex. Fluorescence from GO arises from the recombination of e-h pairs in localized electronic states of various configurations. Having said that, the exact mechanism is still unknown. However, researchers have attempted to provide some crucial insights and interpretation for their observations, which we summarize below. Before we go into those details, excitation dependent fluorescence will be discussed.

GO depicts excitation dependent emission as observed by many groups.^{86–88} The reason for excitation dependency is that different transitions are possible from the CBM and nearby localized states to the wide-range VB. While the lack of emission for the excitation above the band gap^{5,37} can be due to the fact that the excitation energy is either dissipated as heat or injected into the adjacent metallic phase of the carbon sheet.⁷⁷

The emission from GO is in clear contrast to the general semiconductors. In the case of general semiconductors the band edge transition and subsequent recombination yields PL. One of the explanations given for the fluorescence of GO is as follows. The fluorescence from GO arises from e/h recombination in localized sp² electronic states which are confined within the sp³ matrix, *i.e.* confinement of π -electrons (please see Section 3.4 for size dependent effects).⁷¹⁻⁷³ Although sp² clusters are under quantum confinement,⁶ there are no discrete energy levels, however the local energy gap is determined by the cluster size. It means that for a given sample, the size differences in the clusters produce multiple wavelengths. Hence the attribution of wavelengths to the 'average cluster size' needs to be handled carefully especially when wavelength specific applications are considered. It is notable that GO gives fluorescence when the concentration of sp² cluster is optimum,³⁶ passivated reactive sites,⁸⁹ chemical bonding with fluorescent ions,⁹⁰ or in the form of QDs.³⁷ The typical electronic structure of GO can be schematized as



Fig. 2 Schematic band structure of GO. Smaller sp² domains have a larger energy gap due to a stronger confinement effect. DOS-electronic density of states. Figure redrawn after ref. 36.

shown in Fig. 2, where the black arrows denote the transitions of electrons and holes under suitable illumination (E_{exc}). Upon absorbing E_{exc} , e–h pairs are created followed by non-radiative relaxation and radiative recombination emitting E_{PL} . The emission bands are dependent on electronic band gaps of sp² clusters (mixture of sp² and sp² bonding).^{71,93,94} Moreover the band gap is associated with the size, shape, and fraction of the sp² clusters located within the sp³ matrix.³⁶ For instance smaller sp² clusters depict wider energy gaps because of the relatively higher quantum confinement effect. From the given range of sp² cluster size, it is hard to distinguish the features depicted by each cluster. Hence an integral effect is generally seen. Most of the synthesis methods are not very successful in producing GO with a controlled or predetermined cluster size. Further details on how to calculate the cluster size are given in Section 3.4.

There is an alternative explanation given in the literature for fluorescence from GO.³⁷ In this investigation the authors have used a hydrothermal technique to cut GO sheets into QDs which emit blue color. The authors suggested that the emission occurs from zigzag sites, where their ground state is in a triplet state similar to carbene. This can be described as $\sigma^1 \pi^1$ as shown in Fig. 3. The argument is based on the fact that the fluorescence originates from the oxygeneous functional groups as seen earlier in the case of carbon nanoparticles,75,76,95 functionalized CNTs74,96 and surface-oxidized Si nanocrystals.97 However, Loh et al.6 suggest that the enhancement of fluorescence with reduction excludes oxygen containing functional groups from the possible origin.^{15,36,39} Although it is convincing that the exclusion is drawn based on the references^{15,36} and,³⁹ according to Loh et al.⁶ the localized sp² cluster and structural defects during the reduction⁹⁸ seemed to be a more suitable explanation for the origin and the enhancement of blue fluorescence.³⁶ On the other hand Chien et al. suggested that the visible emission might arise from defect related states within an interface.⁵⁸



Fig. 3 Schematic of the electronic structure at the zigzag edge site similar to carbene. Dashed (excitation) and solid arrows (relaxation) for σ - and π -states. Figure redrawn after ref. 37.

Based on the following reasons it is vital to discuss and reconsider the previous argument (sp² cluster localization) to explain the emission from GO. Upon reduction, it is true that the density of oxygen containing functional group decreases. The fluorescence intensity or QY, of course, depends on various factors such as absorption efficiency and the balance between radiative and non-radiative recombinations. Oxygen containing functional groups are eliminated from the emission mechanism due to the enhancement of fluorescence upon reduction.15,36,39 Conjointly, the method of reduction is a key factor to consider, in case if the process enhances radiative or non-radiative paths. For example, in ref. 15 three different methods were employed to reduce the GO yielding Gra. Viz. thermal exfoliation at high temperatures, heating nanodiamond in an inert atmosphere and arc discharge of graphite electrodes in the presence of H₂/He. This few-layer-Gra was subjected to acid treatment under microwave irradiation to yield GO. Subrahmanyam et al.15 suggest blue emission centred around 400 nm from as-prepared Gra samples, which implies that complete conversion of GO into Gra did not take place through the above three reduction processes. To emphasize, fluorescence in Gra is assisted by phonons.³⁴ Apart from the above mentioned differences, the intensity scale on the fluorescence spectra or the details of QY were not given by the authors in ref. 15. In ref. 36 the authors have used hydrazine for the reduction of GO. It is undisputed that hydrazine treatment decreases the density of oxygen containing functional groups. However some of the reports suggest enhancement of blue fluorescence and quenching of the initial yellow-red fluorescence³⁹ in addition to the following points. In the case of exposure to hydrazine vapor the functional groups are reduced in the following order as suggested by Mathkar et al.⁵⁹ (i) phenol and carbonyl groups are the first to be reduced, then (ii) epoxide moieties and finally (iii) tertiary alcohols. In this context it is notable that the electron withdrawing capacity (acidity) depends on the functional group, thereby a variation in the electron DOS of rGO is expected. Furthermore, hydrazine treatment can form $C=N^{50,99-101}$ bonds on rGO. It is also found that the fluorescence intensity of GO is greatly enhanced with no spectral shift after a short exposure of hydrazine vapors.³⁶ During hydrazine monohydrate reduction XPS has evidenced C=N functional groups,⁹⁹ resulting from a reaction as explained in the ref. 100 and 101. Furthermore, the reduction of GO is accompanied by some nitrogen incorporation from the reducing agent (C/N = 16.1 by elemental analysis). This is presumably through a reaction of hydrazine hydrate with the carbonyl groups of GO.⁵¹ Notably, the incorporation of 'N' in the rGO is suggested to take

place via other functional groups such as lactones, anhydrides, quinones with which hydrazine can react.⁵¹ Hydrazine is found to be efficient to remove in plane functional groups such as epoxy and hydroxyls, however, the edge moieties such as carboxyl and carbonyl stay intact.47-49 Another study suggests that the hydroxyls on the basal planes of GO were not removed by hydrazine hydrate even at elevated temperature.⁵⁰ Furthermore this study also suggests that the carbonyl and carboxylate groups formed the C=N bonds of hydrazones.⁵⁰ After hydrazine vapour treatment,⁵³ incorporation of nitrogen at a substantial level was confirmed by XPS analysis and attributed to partial reduction of carbonyl groups to hydrazone groups.^{51,52} It is also important to consider the synthesis method of GO against the hydrazine reduction process as the former plays a major role in determining the functional groups, density and their physical location on the graphitic plane. As the reduction takes place the distance between the sheets decreases because of the π - π interactions. Given the discrepancy in the literature, it is highly recommended that the effect of hydrazine on the type (synthesis method) of GO requires thorough investigation.

In the context of GO QDs, the fluorescence intensity from as synthesized QDs is higher than its annealed (200 °C in vacuum) counterpart apart from a blue shift.³⁶ During the thermal annealing process, formation of intermediate phases was observed by Jeong *et al.*¹⁰² These phases were attributed to the conversion of hydroxyl groups into epoxide and carboxyl groups. As a consequence the interlayer distance is increased and the carbon backbone switches to a sp³ structure.¹⁰² Similar observation and attribution is suggested in a study by Cuong *et al.*¹⁰³ Furthermore in molecular dynamics simulations the formation of highly stable carbonyl and ether groups was observed in the thermal reduction process.⁵⁶ Hence the optical properties depicted by the thermally reduced GO should consider the presence of these functional groups and the associated influence on the emission properties.

The existence of the O2p level and its active participation were discussed in the context of the TiO_2/GO heterointerface (Fig. 18d).⁷⁷ In this study IOT (reduced symmetry at the interface,¹⁰⁴ type-II fluorescence¹⁰⁵) was observed between TiO_2 and the O2p of GO. Under suitable illumination, the electrons localize in the CB of TiO_2 while the holes can either relax to a defect level or injected to the O2p level. The optical recombination of electrons from CB of TiO_2 with that of holes in O2p levels of GO gives fluorescence (IOT). The details of IOT will be discussed more elaborately in Section 7.2.

We point out another important study by Zhang *et al.*¹⁰⁶ in which the authors have studied the optical properties against the self-rolling effect of chemically derived graphene sheets. For concentrations less than 10 mg mL⁻¹, these sheets have shown self-rolling, and aggregated at higher than the said value. The earlier studies in which the fluorescence quenching effect is reported may be reconsidered, as the rolling of sheets severely influences the electronic absorption and emission properties. As a matter of fact, numerous studies evidenced that Gra acts as an electron reservoir, where the photogenerated electrons are collected from an adjacent/accompanying semiconductor.^{29,32,33}

Perspective

Aggregated sheets have shown a clear deviation from the Beer-Lambert law. Apart from these, the absorptivity was decreased and spectral shapes were changed. Rolled sheets depicted new absorption (at 500 and 960 nm) and emission (after 500 nm) bands with decreased emission efficiency.¹⁰⁶ Furthermore this study also suggests that the emission mechanism for single and double layered GO or rGO needs to be re-examined. Self-rolling can be avoided by choosing an appropriate solvent, however, it associates another complexity such as 'dielectric constant' as it plays a key role in the emission process and its energy.⁶ Having said that, for sheet dimensions in the range of $1-10 \,\mu\text{m}$, their dispersion and solid sample have shown comparable fluorescence.³⁸ Extending the argument of self-rolling, with the increasing reduction level the π - π interaction among the sheets also increases and hence the carrier dynamics may be influenced significantly. Finally, similar to the effects from 'hydrazine reduction', the effect of 'dielectric constant' should be investigated further.

In the band diagram of second explanation for the fluorescence, the CB of the localized sp² domains are assigned to the π^* orbitals, while the VB changes from the π to O2p orbitals.⁴¹ Ref. 41 contains discussion of the results from local DFT simulations *via* first-principles. The energy of the indirect band gap increases with the increasing degree of oxidation, *e.g.* ~2.7-3.2 eV for the GO samples studied in ref. 107. Relatively higher band gap causes extremely weak absorption for GO in the visible range.^{90,107} The changing of VB from the π to the O2p orbitals is also suggested by Jeong *et al.* where the HOMO level shifts downwards opening the band gap.¹⁰⁸ It will be very useful, if wavelength selective photodetectors based on GO or rGO are studied while combining the well understood materials. This allows us to elucidate the energetic location of bands and carrier dynamics there in.¹⁸

3.3 Role of prominent functional groups, tunable band gap

In the previous section we mainly discussed two mechanisms that may describe the fluorescence in GO and rGO. In this section we will see how the functional groups inflect the optical properties.45 It is vital because when GO is reduced with hydrazine (Section 3.2) the oxygen related functional groups follow a sequence⁵⁹ where phenol and carbonyl groups are the first and tertiary alcohols are the last to be reduced. An experimental investigation of GO and rGO has also suggested that the oxygeneous functional groups play a major role in determining the band gap.²³ A mixture of oxygen and hydroxyl groups with a coverage of 100%, 75%, 50% depicted band gaps of ~2.8, 2.1 and 1.8 eV, respectively.²³ The control of the density and coverage of these functional groups allows us to tune the band gap of rGO. In a study by Johari et al.45 ab initio DFT based simulations were performed to understand the electronic and optical properties of periodic structures. In this investigation⁴⁵ GO with different coverage densities and compositions of functional groups (epoxides, hydroxyls and carbonyls) were studied. The key findings were as follows. (i) Optical band gap decreases rapidly (4.0 to 0.3 eV) with an increase in the size of the hole or defect in the case of carbonyl groups (an O to



Fig. 4 Fluorescence spectra for (a) GO-1, (b) GO-2, (c) GO-3, and (d) GO-4 films at different λ_{ex} . Reproduced with permission from ref. 67.

C ratio from 0 to 37.5%). When epoxy and hydroxyl functional groups vary from 25 to 75%, π + σ plasmon is found to depict a significant blue shift (\sim 1.0–3.0 eV) unlike the π plasmon peak which is less sensitive. Furthermore, the increase in carbonyl groups on the basal plane creates holes and consequently the π plasmon peak is shifted by ~ 1.0 eV when compared to that of the pristine Gra. This study shows that the earlier argument of method of synthesis is an important factor to consider, where the density of these oxygeneous functional groups varies depending on the process. Taking the discussion a step forward, if the epoxy groups on GO are converted (oxygen plasma treatment) into carbonyl groups⁶⁷ apart from the excitation dependency, the luminescence spectra depicted distinct features (Fig. 4). As the oxygen pressure increases (GO-2 to GO-4: sp³ hybridization increases) the shoulder at 530 nm disappears apart from a spectrally invariant emission at 487 nm. Clusters of larger sizes are more prone to oxidation introducing nonradiative paths (epoxy & carbonyl) and dangling bonds which result in quenching of emission at longer wavelengths (550-650 nm). Interestingly, the QY increases from GO-2 to GO-4 compared to GO-1.109 The emission has occurred from a range of GO dimensions, where red to NIR is observed in nanosized aqueous GO dispersions.^{25,26} Note that the GO in these two cases is functionalized with PEG.

Experimentally a control on the reduction of functional groups of GO is achieved through hydrazine vapor exposure. It enables the band gap tunability from 3.5 to 1 eV (Fig. 5).⁵⁹ Refer to Section 3.2 for more details related to this method of reduction. Within the first 8 h of hydrazine exposure the optical band gap is seen to fall rapidly from a starting point of 3.5 eV. Precise control on the reduction time yields the band gap that we require, however, the density of functional groups cannot be controlled with this process. As an aside, spectroscopic ellipsometry can be employed to estimate the band gap by applying the Lorentz oscillator model which provides accurate energy level distribution in GO or rGO.^{23,110} Apart from UV-Vis spectroscopy,



Fig. 5 Band gap modulation upon exposure to hydrazine vapors along with a schematic rGO structure at selected time intervals. Reproduced with permission from ref. 59.

cyclic voltammetry can be used with which the edges of CB and VB can be determined.⁵⁹ Crucially, it should be unveiled whether these techniques yield comparable results for GO and rGO in the background of their complex band structure. Controllable oxidation of Gra is also a subject of investigation¹¹¹ however, Wang *et al.* did not provide an estimation of the band gap with reference to different oxidation levels.

3.4 Quantum dots

The applications of GO QDs have spread into biomedical engineering because of their size dependent emission properties. They are cell imaging, drug delivery,²⁵ selective detection of Cu²⁺ ions²⁸ etc. Notably the size dependent emission of GO QDs is similar to that of carbon QDs.⁷⁵ GO QDs were synthesized variously.^{37,112} For example 1-4 nm sized QDs (referred to as graphene quantum dots in ref. 112) were synthesized from carbon fibers which not only offer a cheap alternative route but also a control of the size enables tunable fluorescence.112 In vivo toxicology effects are also studied for carboxylated GO QDs³¹ (Fig. 6). In Fig. 6 schematic of synthesis, TEM, DLS and fluorescence properties (at 505 nm) were shown for carboxylated GO QDs. KB cells were treated with these carboxylated GO QDs and the corresponding CLSM images is shown. Density gradient ultracentrifuge is employed to obtain monodisperse GO QDs¹¹³ where the UV-Vis and fluorescence spectra revealed that the properties of samples are highly dependent on their sheet size and degree of oxidation. Eda et al.³⁶ attributed the emission to quantum confinement of sp² clusters which in turn connects to its band gap.^{71,93,94} Moreover the band gap depends on the size, shape and fraction of the sp² clusters.³⁶ Initially the cluster size (L_a , Å) was estimated by Tuinstra et al.¹¹⁴ in 1970 by an empirical relation as $L_{\rm a} = 43.5 (I_{\rm D}/I_{\rm G})^{-1}$ which was later verified by Knight *et al.*¹¹⁵ with additional data points. Note that the method shown in ref. 114 underestimates the crystallite size if there is a dominant effect of small crystallites, despite it can be validated with the crystallinity from XRD. However, the linear relation suggests that the Raman intensity is proportional to the 'boundary' in the sample.¹¹⁴ UV-Vis (sp² clusters size < 1 nm) and red-IR emission (sp² cluster



Fig. 6 (A) Synthesis and fluorescence of GO QDs, (B) fluorescence intensities at 505 nm wavelength, (C) TEM images; scale bar is 50 nm for the left image and 10 nm for the right image, (D) HR-TEM image (scale bar = 5 nm) showing the edge structure of lattices formed in QDs, inset shows Fourier transformed image, (E) size distribution of the carboxylated Gr QDs measured by DLS and (F) CLSM images of KB cells treated with the carboxylated QDs (scale bar = 50 μ m). Reproduced with permission from ref. 31.

size > 2 nm) are observed by Eda *et al.*³⁶ As synthesized GO has a larger sp² cluster size (4.83 nm) with a narrower band gap emitting in the green-to-red region. After annealing, the cluster size (3.95 nm) as well as emission intensity is decreased apart from a blue shift in the emission spectrum. Other studies have shown similar results for sp² cluster sizes of 2.5–8 nm.^{5,38,43,71,94,103,116–121} The authors attributed the decreased cluster size to the nucleation of sp² domains in the sp³ matrix. For the cases in which the thermal process is employed for the reduction the earlier discussed consequences should be considered (Section 3.2).

GO QDs (referred to as graphene quantum dots) were synthesized by Peng *et al.*¹¹² where the variance in the size offers a tunable band gap and consequently the emission characteristics can be controlled. The UV-Vis absorption spectra were shown in Fig. 7 of GO QDs synthesized at 80, 100, and 120 °C. See the inset of Fig. 7 for digital photographs under UV light. A clear blue shift is noticed from 330 to 270 nm with increasing synthesis temperature. The fluorescence spectra (Fig. 7b) can be understood from the average sizes, shape and defect densities.⁶⁴ The size differences may cause variation in density and nature of sp² sites, which results in varying band gap (3.90 to 2.89 eV).

Note that this trend is similar to the quantum confinement effect at lower particle sizes (1–10 nm).¹²² From the PLE spectra two new transitions (at 284 and 318 nm) were seen, where they can be considered as a transition from the σ and π orbital (HOMO) to the LUMO (Fig. 7c) in contrast to π - π * transition. In the case of carbine for a triplet ground state energy differences



Fig. 7 (a) UV-Vis spectra of GO QDs (A–C), correspond to the reaction temperatures at 120, 100, and 80 °C, respectively. Inset of panel a is a photograph of GO QDs under 365 nm illumination. (b) Fluorescence spectra for λ_{ex} 318 (A), 331 (B), and 429 nm (C) and (c) electronic transitions of triple carbenes at zigzag sites observed in the optical spectra for blue emission. Reproduced with permission from ref. 112 while part c is taken from its supplementary information.

between the σ and π orbital should be below 1.5 eV,^{123,124} where it is 0.47, 0.82, and 1.24 eV for blue, green and yellow emission, respectively. Under alkaline conditions, the GO QDs emit strong fluorescence, while acidic conditions quench the PL, because the free zigzag sites are protonated while forming a complex.¹¹² In general the quantum sized materials of course behave differently from their bulk counterparts. Nevertheless, sp² clusters localized in the sp³ matrix of 1–10 µm overall size is different from that of sp² clusters in a quantum sized particle of 1–10 nm. In the former case the localization is constrained within the sp³ matrix where the edge effects can be largely ignored. This is in clear contrast to the latter case where the edge effects are as prominent as the surrounding sp³ matrix.

QY can be calculated by comparing the integral intensity with constant absorbance.¹⁰⁹ If we take a look at the QY of the GO, it is relatively low (6.9% ref. 40) at times as low as less than 1%³⁸ which can be because of two main factors.⁸¹ The presence of (i) isolated sp² domains and (ii) reactive sites such as the epoxide groups inducing nonradiative recombination. It is expected that when the surface is modified, the reactive sites may be passivated and hence luminescence yield may improve. Defect states within the interfaces may cause nonradiative transition, which might reduce the emission intensity¹²⁵ and thus the QY. In some cases no emission is observed until GO was subjected to specific modifications such as appropriate control of the sp² cluster concentration,³⁶ or surface passivation of the reactive sites.⁸⁹

3.5 Doping

Similar to regular semiconductors^{16,21} GO is subjected to doping. In this section we will discuss the effects of substitutional doping while that of surface electron transfer^{126,127} will be discussed later. Doping of GO is rather interesting and extensively investigated^{99,128,129} especially with nitrogen,^{99,129} boron,¹²⁸ halogens¹³⁰ etc. In the context of fluorine doping, a completely fluorinated graphene behaves as a thinnest insulator and the only stable stoichiometric graphene halide (C₁X₁).¹³⁰ Fluorinedoped rGO is reportedly a better substrate for surface enhanced Raman spectroscopy than unmodified rGO. Since F doped rGO or GO doesn't show any emission, we will not discuss their details. However, the reader is advised to refer to a recent review by Karlicky et al.¹³⁰ In the process of doping, formation of other phases is an important issue. For example, B doping has resulted in the presence of B₄C, B_C, BC₂O, BCO₂ and B₂O₃.¹²⁸ Recently, the energy-level structure of N-doped GO QDs was discussed.¹²⁹ Simultaneous doping of B and N doping is also possible, where GO is converted into boron carbonitride by substitutional doping.¹³¹ Interestingly, after the doping process (at 900 °C), a significant amount of oxygen content in the GO is evidenced from XPS. Essentially the BN phase is formed within the GO matrix, cf. boron doping and secondary phase formation.

Going into the details, a study on N doped GO QDs has revealed vital findings where nitrogen atom creates an intermediate state (Fig. 8).¹²⁹ Note that in ref. 129 the authors refer GO QDs as graphene QDs while significant quantity of oxygen is evidenced from XPS and EELS. For a suitable illumination, the following transitions are possible, where the wavelength equivalent is given in the brackets for each of them. 6.1 eV: $\pi \rightarrow \pi^*$ of C=C (202 nm), 4.6 eV: $\pi \rightarrow \pi^*$ of C=N (274 nm) and 4.1 eV: $\pi \rightarrow \pi^*$ C=O (302 nm), see Fig. 8.

Tang *et al.*¹²⁹ suggested two methods of recombination of excited *e*-*h* pairs. (i) Direct recombination after vibration relaxation, producing fluorescence and (ii) C $\pi^* \rightarrow N \pi^*$ and



Fig. 8 A schematic diagram illustrating the energy levels of the nitrogen doped GO QDs. Reproduced with permission from ref. 129.

N $\pi^* \rightarrow O \pi^*$, followed by vibration relaxation and finally radiative recombination. Process (ii) occurs because of the nitrogen doping *via* intersystem crossing.¹²⁹ The interpretation of emission from GO is based on the involvement of oxygeneous functional groups in contrast to sp² localization. Significant enhancement of blue emission was achieved after doping rGO with nitrogen (2.3–4.7 at%) *via* thermal annealing in the presence of ammonia gas for different time periods.⁹⁹ During this process, formation of graphitic carbon nitride (C₃N₄) in α and β phases was also detected. These phases impose significant changes in the emission and electronic properties. The emission mechanism explained in ref. 99 is based on localization of sp² clusters.³⁶

A typical emission spectrum from boron doped GO is shown in Fig. 9. The emission is attributed to the recombination of *e*-*h* pairs within the electronic band gaps of sp² clusters^{71,93,94} including the effects from size, shape and fraction.³⁶ The fluorescence spectrum of as synthesized GO consists of three components centered at 520, 716, and 827 nm, while the size of sp² clusters increased to 6.90 nm after B-doping. Despite the increase in the sp² cluster size the green emission peak is blue shifted (to 494 nm) as compared to that of annealed GO with a decrease in its intensity. The second peak at ~636 nm is attributed to the boron carbide phase (B_{4.23}C emits ~795 nm ref. 132, B_{4.3}C, B_{6.5}C, and B₁₀C emit > 595 nm ref. 133).

3.6 Covalent modification

In the previous section we have seen substitutional doping and its effects on emission properties of GO and rGO. In this section, we will see the variations in optical properties when GO or rGO were covalently functionalized with various moieties. The covalent functionalization is facilitated through the surface functional groups of GO or rGO. In this direction, researchers have studied considerable types of modifications aiming at various applications^{81,134} including nonlinear optical properties.^{135–137} Typical modifications are surface passivation of the reactive sites,⁸⁹ chemical bonding with fluorescent ions⁹⁰ *etc*. The covalent modification has various advantages such as improved solubility in intermediate organic solvents, coupling with other functional materials where the spacer length can be tuned and the quantity of loading can be increased. In a typical example, the functionalization can take loading as high as 5 wt% of dye.⁷⁹

In an approach shown recently⁷⁹ the covalent attachment to GO does not alter the absorption and emission properties of the dye. On the other hand the pH sensing capability is achieved through the amidic group *via* reversible protonation. GO layers were functionalized with azo-pyridine⁸¹ at an interlayer separation of 0.9 nm showing a bright blue emission *via* excited ESIPT. The fluorescence spectrum ($\lambda_{ex} = 416$ nm) of the GO solution (QY = 0.03%) depicted a broad peak at ~560 nm.¹³⁸⁻¹⁴⁰ This peak is blue shifted to 470 nm for the GO-azopyridine (QY = 8%) and the intensity increases 400% with respect to GO. Basically, functionalization not only creates but also enhances the luminescent centers in the composite. The enhanced optical emission is because of ESIPT between the –OH group (alpha) of the phenol moiety and the azo group. This is similar to substituted hydroxyl benzaldehydes



Fig. 9 Emission spectra of as-synthesized GO, annealed GO, and B-doped GO. Reproduced with permission from ref. 128.

where the emission is due to the keto (H) form and the enol-Azo form of ESIPT. $^{\rm 141}$

The covalent functionalization of GO with anthryl moieties is interesting.¹³⁴ The emission properties of 2-aminoanthracene (pale yellow under daylight, cyan (491 nm) under 365 nm) were significantly changed when functionalized with GO (dark red under daylight, blue (400 nm) under 365 nm). This leaves us with a shift of ~91 nm. Such a large shift is simply attributed to the interaction between the anthryl moieties and GO, however, the shift is almost absent when the components are physically mixed. Hence the interaction between π -orbitals is insignificant for the shift. Hence a deeper investigation is required to



Fig. 10 Schematic mechanism of fluorescence from the Mn²⁺-bonded rGO where solid and dotted lines represent the radiative and nonradiative relaxation processes, respectively. Reproduced with permission from ref. 90.

explain how an unconjugated covalent bond causes such a significant shift.

Chemical bonding with fluorescent ions such as Mn^{2+} has shown interesting results.⁹⁰ The authors attribute emission from rGO to the π - π * transitions due to localization while resonance energy transfer takes place from the Mn^{2+} ion to π * states of rGO (Fig. 10).⁹⁰ In this hybrid, Mn ions are bonded to the carboxyl groups of rGO which places the ion in the close proximity of sp² cluster. Finally the authors note that the emission from GO is enhanced.

4. Nonlinear optical response

In principle GO can be a more suitable material for optical limiting applications than Gra because of the tunable energy gap. It would be appropriate to briefly describe some unique nonlinear optical features depicted by GO. By definition, a nonlinear property is that the transmission decreases with increasing light intensity (good linear absorption at low input levels). This feature is extremely useful for eye protection where a broadband (visible to IR if possible) optical limiter is demanded. The nonlinear response of GO is different from that of the other carbon allotropes while similar to organic materials.¹⁴² In the case of GO, for picosecond pulses two-photon absorption is predominant, while for nanosecond pulses excited state nonlinearities play a vital role.¹⁴² Although Gra is considered for such applications,⁶ GO has its own advantages such as 2D nature and more importantly its functionalizability. The functionalizability allows covalent bonding of organic dye molecules (see Section 3.6) or other complementary optical materials and composites.143,144 Interestingly, GO depicts better optical limiting response than fullerene (C_{60}) as shown by various groups.^{145,146} Experimentally it is evidenced that covalent functionalization with C_{60} ,¹³⁵ porphyrin,^{135,136} or oligothiophene¹³⁷ improves the nonlinear optical performance in the nanosecond region. These studies suggest that the hybrid materials have better nonlinear absorption

via photoinduced electron or energy transfer. Fluorinated GO has shown higher nonlinear absorption, nonlinear scattering and optical limiting threshold which are about an order of magnitude better than GO.¹⁴⁷

5. Ionic interactions

In the earlier sections we have seen that the functional groups on the GO may be one of the causes for the emission where they open the band gap of graphite. These functional groups are mainly oxygen-contained, which are prone to external interferences such as ions (cations and/or anions). In the following we will discuss the emission dependent on H^+ (pH) and other ionic species in two different subsections.

5.1 pH dependent optical emission

Essentially, the Fermi level of GO is shifted depending on the pH values where the electronic structure of GO is manipulated. As a result different emission colors are noticed.⁶⁹ Note that this is in contrast to the GO-azo pyridine composite, where the increased symmetry of the π - π * state decreases the Franck-Condon factor. Consequently radiationless decay is decreased, thereby the fluorescence from such composites gets brighter with decrease in pH.81 Blue fluorescence from GO QDs is found to be pH-dependent where they were derived from cleaving CNT possessing zigzag sites.37 The suggested mechanism hinges on the protonation of the emissive zigzag sites where their ground state is $\sigma^1 \pi^1$. The fluorescence can be recovered when deprotonated (alkaline conditions). Multicolour fluorescent GO was synthesized by cleaving CNT upon oxidation⁶⁹ while the fluorescence depicted bathochromic shift¹⁴⁸ which was attributed to deprotonation of -OH and -COOH groups.^{149,150} It is also notable that ionic-liquidassisted electrochemical exfoliation showed similar results.¹⁵¹ The intensity of the emission from azo-pyridine functionalized GO⁸¹ can be controlled by adjusting the pH value. In this case the radiatiave surface defects are passivated.149,152 The intensity changes are because of the protonation and deprotonation of the functional groups which may cause electrostatic doping (i.e. shift of the Fermi level as seen in the case of carboxylate SWNTs¹⁵³). Interestingly, this is in contrast to the fluorescence of GO QDs with change in pH where the intensity of fluorescence decreases with decreasing pH (13 to 1).³⁷ In a study by Peng et al.¹¹² the GO QDs emit strong fluorescence under alkaline conditions. While under acidic conditions the fluorescence is quenched because of the protonated free zigzag sites.

5.2 Other ionic species

Since GO QDs consists of oxygen containing functional groups they can act as a sensing platform when interacting with ions, *cf.* protons, in the case of pH. The variation in the emission intensity is related to the molecular interaction. The quenching occurs because of inner filter effects, creation of non-radiative paths, electron transfer process and ion binding interactions.¹⁵⁴ In this section we will see two types of effects because of ionic interactions. (i) The quenching of fluorescence by itself in the presence of guest ions and (ii) quenching of the fluorescence of other materials.

Generally quenching of fluorescence of the host in the presence of guest ions takes place through collisional or dynamic quenching. The Stern–Volmer equation¹⁵⁵ describes the dynamic and collisional quenching via $F_0/F = \tau_0/\tau = 1 + k_q \tau_0[Q]$, where F_0 and F are the fluorescence intensities before and after the arrival of guests, respectively. k_q is the rate constant of dynamic (collisional) quenching; τ_0 and τ are lifetimes of fluorophore before and after the arrival of guest ions, respectively; and [Q] is the concentration of the guest ions in the solution. In the context of static quenching, a non-fluorescent complex forms between the host and guest and as a result the life-time of the fluorophore is unperturbed, *i.e.* $\tau_0/\tau = 1$. Now, the $k_q \tau_0$ is called as association constant.¹⁵⁵

GO QDs were employed as selective ion sensing materials where the quenching of fluorescence was observed (inversely proportional) under the influence of $Cu^{2+,28}$ The intensity was linearly decreasing within the range of 0–15 μ M of Cu²⁺ ions with a maximum detection limit of 0.226 µM. Authors also suggest that the quenching mechanism is predominantly static in nature as described by Stern-Volmer equation.²⁸ The interaction with P^- and P^+ was studied with Au NPs and GO separately by Mamidala et al.⁹¹ Emission from various combinations were shown in Fig. 11a and b. We can see the quenching of emission at 640 nm from $GO + P^+$ complex in contrast to GO + P⁻ complex. This indicates that the interacting donor-acceptor complexes are formed between opposite charges. The quenching is attributed to photoinduced electron or/and energy transfer.¹⁵⁶ This interaction is also reflected in the fluorescence lifetimes (Fig. 11c and d and Table 1 for the time scales). On the other hand, in the case of positively charged picket-fence porphyrin the interaction is attributed to the π - π type.¹⁵⁷



Fig. 11 Spectra of P⁺, P⁻, Au + P⁺, Au + P⁻, GO + P⁺ or GO + P⁻ in water dispersion (a) and (b) fluorescence, $\lambda_{ex} = 430$ nm. (c) and (d) decay curves. The instrument response function is shown in violet color trace. Figure reproduced with permission from ref. 91.



Fig. 12 (a) Fluorescence excitation spectrum of the rGO and Eu³⁺ complex, inset is the 350–400 nm region, and (b) fluorescence spectrum ($\lambda_{ex} = 314$ nm). The right inset shows the other three distinct emission spectra at different λ_{ex} and the left inset shows the color coordinates ($x = \sim 0.66$ and $y = \sim 0.32$). Reproduced with permission from ref. 158.

Previously, interaction of GO with charged porphyrin⁹¹ has been discussed; similarly Eu3+ ions are also a subject of investigation against the fluorescence from rGO (Fig. 12).¹⁵⁸ In this study, the authors referred to rGO as graphene as it contains very low percentage of oxygen. Nevertheless, the complexation requires oxygen functionalities on graphene, hence, we will be referring to this as rGO instead of graphene. This complex is shown to quench the fluorescence of Rhodamine-B dye while the complex of Eu³⁺/rGO is active ($\lambda_{ex} = 314 \text{ nm}, \lambda_{em} =$ 614 and 618 nm). Note that the various oxygeneous functional groups on rGO spatially distributed around the Eu³⁺ ion should be at low symmetry sites.¹⁵⁹ This is in contrast to an earlier explanation,⁹⁰ where an energy transfer takes place from Mn²⁺ to the localized states of sp² on rGO. In this case the involvement of oxygen containing functional groups can be avoided, despite the covalent bond between rGO and Mn2+ (see Section 3.6 and Fig. 10). Also see anthryl functionalized GO and its emission properties¹³⁴ in Section 3.6. In the PLE spectrum (Fig. 12) the interacting oxygen functionalities and Eu³⁺ have shown a strong band at 314 nm^{160,161} while the other five peaks are attributed to f-f transitions of the Eu3+ ions. The authors suggest triple-exponential decay (average lifetime \sim 391.13 µs) due to the differences in the ligand environments in the rGO around Eu³⁺. The combination of GO is not limited to Eu³⁺ but extends to europium oxide.162

6. $\pi - \pi$ type interactions

Moving onto the combinations with organic semiconductors, Yang et al.163 studied fluorescence from the GO-P3HT nanocomposite heterostructure and suggested a π - π interaction between the two components.^{164–166} In this heterostructure P3HT chains are attached to rGO while the former coats a thin-layer on the latter. Later in 2012, PDS and pump-probe techniques were employed on the GO-P3HT layer-to-layer hybrid, and the results support the earlier argument of π - π interaction (Fig. 13).⁹² In the solution phase, the normalized PL spectra of P3HT, GO-P3HT and rGO-P3HT are of comparable intensity (Fig. 13a), with small differences in the range 540-600 nm, see inset. In contrast to this, in the solid phase the presence of GO or rGO has significantly quenched the emission from P3HT (Fig. 13b) via π - π (weak Coulombic) interactions. See Table 1 and Fig. 13c for decay times and measurements, respectively. Furthermore the transient response studies (650 nm, Fig. 13d) indicated that the GO-P3HT composite did not show any stimulated emission. However a photoinduced absorption signal with two decay times ($\tau = 1.4$ and 38.5 ps) is observed in contrast to pure P3HT which depicted stimulated emission. As a result, an ultrafast charge dissociation of P3HT excitons¹⁶⁷ takes place at the interface and charge pairs are injected into GO as fast as 1.4 ps. In the case of rGO-P3HT the electrons generated in P3HT are injected rapidly into rGO. In this context both GO and rGO are very useful in solar cells where fast transfer of photogenerated charge is the primary objective.¹⁶⁸ In the case of covalent functionalization between P3HT and GO^{169} the overall fluorescence quenching includes dynamic quenching and forms a non-fluorescent ground-state complex.¹⁶⁹ Also this π - π interaction blue shifted (~4 nm) the absorption maximum of P3HT. It would be more conclusive if the XRD patterns were investigated on solid samples, where the consequence of π - π



Fig. 13 (a) Normalized fluorescence spectra, (b) fluorescence intensity while P3HT is 0.1 mg mL⁻¹, (c) TCSPC decay curves and (d) relative changes in transmission for varying pump (10 μ J cm⁻²)-probe delays; $\lambda_{ex} = 400$ nm and $\lambda_{em} = 650$ nm. The inset shows the magnified spectrum of rGO-P3HT in the first 2 ps. All cases are dispersion in CHCl₃. Reproduced with permission from ref. 92.

interaction and layer formation can be understood rather precisely *via* (002) interplanar spacing of GO.

It is important to note that the case with PANI is not similar to P3HT or even inorganic semiconductors. When graphene is combined with PANI either through *in situ* polymerization or mixing¹⁷⁰ the emission properties of PANI were preserved suggesting an inappropriate band alignment and possible π - π interaction.

The fluorescence from rGO and its decay life time were enhanced with Rb⁷⁰ through non-covalent bonding. Apart from preserving the native features of rGO such as excitation dependent fluorescence, a slight shift in the peak position is observed. From the fluorescence decay (Table 1) it is suggested that the shorter component has higher contribution (~84%).^{58,87} Another study on π - π interactions of rGO with positively charged picket-fence porphyrin¹⁵⁷ suggested a quenching of fluorescence from porphyrin under the influence of rGO.

7. Heterointerfaces

7.1 Photovoltaics

GO and rGO are proven to be potential for photovoltaic applications. For example, the hole transport property of PEDOT:PSS can be improved with the addition of GO at a suitable concentration.9 Furthermore such combinations can yield a band gap larger than 1.1 eV for 10-15 wt% of GO, while the carrier transport property is majorly determined by the fine structure of host PEDOT:PSS.¹⁷¹ At a certain concentration, GO in dve-sensitized solar cells acts as an electron collector and transporter resulting in an enhanced photovoltaic performance.¹⁷² Moreover it also improves the transfer of electrons from the films to the FTO substrate.¹⁷³ In contrast to this, partially reduced GO is employed as an active layer and rGO is employed as electron and hole collecting layers. This symmetric device configuration is shown in Fig. 14a. The device has depicted a $V_{\rm oc}$ of 0.017–0.014 V. However the authors in ref. 174 did not present any fluorescence data from partially reduced GO and rGO in the case if there is any.^{15,36,58} Despite this, this study is remarkable where it employs rGO as an active material in the device. Although the fluorescence from rGO is debatable, however, the energetic states and their alignment can be deduced by fabricating pn-junctions.¹⁸ Such studies can unveil the information about charge generation and subsequent separation. Composite HJs were studied



Fig. 14 (a) Schematic energy level diagram of rGO based solar cell (b) band diagram of the crystalline silicon (N c-Si) and PEDOT:PSS/GO composite junction under small FB. Figure redrawn based on ref. 171 and 174.

for electrical characteristics where they can be integrated into the well established silicon devices.¹⁷¹ The authors have studied carrier transport in crystalline-Si (100) (c-Si)/conductive PEDOT:PSS composite HJs.¹⁷¹ See Fig. 14b for the band diagram under a small FB. The results suggest that the carrier transport mechanism is changed from diffusion to the space-charge recombination with the increase of GO content in PEDOT:PSS. Upon introducing GO in PEDOT:PSS, apart from the improvement in the ideality factor (GO-PEDOT:PSS-2.91 PEDOT:PSS-1.12) the efficiency of the device is enhanced.^{171} The cell characteristics are η = \sim 10.3%, $J_{\rm sc}$ = 28.9 mA cm⁻¹, $V_{oc} = 0.548$ V and FF = 0.675 at a GO content of 12.5 wt% with diffusion and recombination in the space-charge region. Improvements in charge extraction efficiency and reduced charge recombination were observed by inserting the rGO-TiO₂ composite layer as an optical spacer between the active layer and Al electrode.¹⁷⁵ This interfacial layer blocks the holes as well. As a result the PCE is \sim 4.18% and \sim 5.33% for TiO₂ and the rGO-TiO₂ interfacial layer, respectively where a similar structure without the interfacial layer has shown a value of \sim 3.26%. It is obvious that defects of GO or rGO influence the device performance. However, in an interesting study by Chang et al.¹⁷⁶ the defects and atomic structure are controlled yielding well regulated infrared PR (responsivity of $\sim 0.7 \text{ A W}^{-1}$) in rGO phototransistors. This study evidenced that the PR is mostly dependent on oxygenous defects. Furthermore external quantum efficiency of \sim 97% and no PR degradation even after 1000 bending cycles are significant.

7.2 Nanocomposites

Nanocomposites are very potential materials in scientific and technological applications in which rGO or GO is employed extensively. The host matrices are inorganic or organic in nature depending on the type of application. Inorganic matrices can be CdSe nanoparticles,¹⁷⁷ ZnO(a)ZnS hollow dumbbells,²⁹ zinc (hydr) oxide,¹⁷⁸ TiO₂,^{77,179,180} Fe-doped TiO₂ nanowires,¹⁸¹ noble metal doped TiO₂,¹⁸² ZnO,^{180,183,184} Ag/ZnO,^{185,186} ZnS,¹⁸⁷ CdS,^{188–191} Ta₂O₅,¹⁸⁰ CdSe,^{177,192} CdTe,¹⁹³ Ag₂Se¹⁹⁴ *etc.* Examples of organic components include PANI,^{170,195} P3HT,¹⁶³ methylcellulose¹⁴³ *etc.* In this section we will focus on the optical properties of these material combinations in the context of charge transfer, where the relative position of HOMO and LUMO levels play a crucial role.

When CdSe NPs were composited with rGO¹⁷⁷ the PL from CdSe is observed to decrease apart from an enhancement in the PR. This indicates that the photoinduced carriers from the CdSe NPs can be transferred to the rGO effectively. A recent investigation196 on ZnO and GO QDs presents important insights in the emission (Fig. 15a) from a composite with an application in LEDs. The MO levels, DOS for pristine and G-O with an epoxy bond (G-O_{epoxy}) including the oxygen PDOS are shown in Fig. 15b. The results indicate that there are significant orbital hybridizations after the chemical bond with the oxygen atom. The mechanism of emission is shown in Fig. 15c. Under illumination the photo-excited electrons from the O2p of the ZnO are transferred to the unoccupied states of G-O_{epoxy}. Then these electrons recombine with the holes in VB of ZnO creating two additional peaks in the spectrum. Such transitions are determined by the selection rule ($\Delta l = \pm 1$), *i.e.* l = 0 or l = 2



Fig. 15 (a) Emission spectra, (b) DOS of graphene and the $G-O_{epoxy}$ model. MO energy is indicated with vertical bars in each calculated DOS. Inset: $G-O_{epoxy}$ model, (c) PL and EL transition scheme for ZnO-GO QDs, (d) band alignment of various components in the LED. Parts (a)–(c) are reproduced with permission from ref. 196 and part (d) is redrawn based on ref. 196.

electrons can recombine with O2p (l = 1). Contextually, DFT results suggest that only p orbitals contribute to the LUMO level of pristine graphene and hence no transitions as l = 1 and the un-hybridized LUMO level splits into three levels with oxygen attachment (LUMO, LUMO + 1 and LUMO + 2). See Fig. 15c for various allowed transitions. The emission from ZnO-GO QDs is deconvoluted into four Lorentzian peaks centred at 379 (band to band), 406 (LUMO + 2 in G–O_{epoxy} to VB of ZnO), 436 (LUMO in G–O_{epoxy} to VB of ZnO) and 550 nm ($V_{\rm O}$ or Zn_{*i*}), according to the authors' attribution.

Optical and electrochemical properties of ZnO nanowires/ GO heterostructures reveal that GO can suppress surface states of ZnO enhancing the UV-emission of ZnO.¹⁹⁷ This enhancement is a balance against the green emission, which is due to V_os in ZnO as widely accepted,¹⁶⁻¹⁸ also see cross references in ref. 17. There is also a possibility that the electrons are transferred to GO due to the energy level alignment (Fig. 16a). Of course, GO can perhaps passivate the surface¹⁹⁸ in which case ionized Vos can be suppressed, thereby enhancing the UV emission. A similar case can be seen in the literature,¹⁹⁹ in which the authors compared PL properties of ZnO nanorods when coated with GO and rGO. Notably, the emission due to interband transition is enhanced when ZnO nanorods were coated with rGO (Fig. 16a). In another example of the GO-ZnO composite,¹⁸³ the green emission (centered at \sim 550 nm) from ZnO was blue shifted (0.15 eV) and quenched upon compositing with GO. The authors suggest additional pathways for the subdued emission via interfacial charge transfer from ZnO to GO.²⁰⁰ In ref. 200 the authors show that the PL quenching increases with increasing concentration of GO without any shift in the PL peak position. This might be because of the preparation technique that is used. It is notable that the electrons from the ZnO were primarily used in the reduction of GO to rGO upon



Fig. 16 Schematic diagram of the electron transfer between (a) ZnO NWs and GO films and (b) Mott–Schottky plot for the CdS-5% rGO nanocomposite in 0.2 M Na₂SO₄ aqueous solution (pH = 6.8), reproduced with permission from ref. 203.

irradiation of UV light. In contrast, to ref. 200 Singh *et al.*¹⁸³ eliminated the electron transfer from ZnO to GO *via* modifying the preparation method. It is also suggested that the interaction is similar to SnO₂-CNT or ZnO-SWNT composites.²⁰¹ Although the suppression of V_{OS} is explicit the mechanism behind such passivation and the creation of additional pathways should be studied further. On the other hand the fluorescence from GO is also seen to quench²⁰² when combined with ZnO.¹⁸⁴

Mott–Schottky plots (Fig. 16b) provide information about the feasibility of transfer of photogenerated electrons to rGO.²⁰³ In the case of CdS nanoparticles, it is thermodynamically permissible for the absorbed O₂ to produce superoxide radicals ($^{\circ}O_2^{-}$) under visible light illumination. The photoinduced electrons are transferred to rGO delaying the recombination process.²⁰³ Similar to the earlier cases the PL intensity from CdS is subdued.^{190,204} By considering the energetic locations²⁰⁵ of CdS ($\chi_{CdS} = 4.00 \text{ eV}$) and rGO ($E_{\rm F} = 4.42 \text{ eV}$), under suitable illumination electron transfer occurs from the CB of CdS to rGO and hence the emission is quenched (inset of Fig. 16b).

The fluorescent spectra from GO grafted CdTe (exciton band at 520 nm) are shown in Fig. 17.¹⁹³ The emission is centred at \sim 540 nm under 365 nm illumination. In the case of GO–Cl, the sample has shown some visible fluorescence may be due to sulfonyl chlorination of the GO. As seen earlier, although GO is itself fluorescent it can quench the luminescence of other



Fig. 17 Fluorescence spectra, $\lambda_{ex} = 365$ nm. The inset shows the optical images $\lambda_{ex} = 365$ nm (top) and under $\lambda_{ex} =$ sunlight (bottom). Reproduced with permission from ref. 193.



Fig. 18 Emission spectra λ_{ex} is (a) 266 nm and (b) 400 nm. The inset of (b) shows the fluorescence spectrum of as synthesized GO, $\lambda_{ex} = 400$ nm. (c) PL decay curves, $\lambda_{ex} = 400$ nm, inset: 0 to 12 ns on a log scale. The fluorescence signal was collected over the entire spectrum of each sample. IRF: instrument response function and (d) schematic of band diagram for TiO₂ and GO, water oxidation potential is set at 0 eV. The dotted arrow red line marks the IOT. Figures are rearranged and reproduced with permission from ref. 77.

materials.^{188,206,207} GO quenched the interband transition (due to fluorescence resonance energy transfer, or nonradiative dipole–dipole coupling between CdTe and GO²⁰⁸) and depicted an emission around 420–450 nm. This is because of the amidation process which creates localized sp² clusters and structural defects.^{15,39} This is similar to CdSe nanocrystals (cubic and hexagonal) where the PL from CdSe is quenched by rGO.¹⁹²

 ${\rm TiO}_2$ and GO alternative layer structure is ${\rm studied}^{77}$ for luminescence properties and decay life times. The emission properties and band diagram (ignoring the presence of any defect-related⁵⁸ states) are shown in Fig. 18. For TiO_2 the emission peak (at \sim 600 nm) is red shifted (\sim 650 nm) significantly upon increasing the λ_{ex} which is attributed to vacancy related defects^{209–211} within the band gap. The QY is as low as $<1\%^{210}$ (Fig. 18c) with a lifetime component that is only a little longer than the ~ 250 ps resolution. In the case of GO/TiO₂, 550 nm band is blue shifted (to ~ 500 nm) while the emission is subdued for rGO/ TiO₂. Authors attribute this blue-shift to the quenching effect, which is more effective on the longer wavelength side of the PL spectrum of TiO2.211 The quenching effect creates non-radiative decay channels and hence a faster PL decay should be noticed. The present decay curves suggest that the fluorescence quenching effect plays a minor role in blue shift. However, the authors attribute the emission to IOT between TiO_2 and the localized sp² domains of GO in a charge-separated configuration. From Fig. 18d, the electrons localize in the CB of TiO2 while the holes can either relax to the defect level or be injected into the O 2p level for both λ_{ex} . The optical recombination of electrons from CB of TiO₂ with that of holes in O2p levels of GO is allowed (reduced symmetry at the interface¹⁰⁴). This is seen as the blue-shifted emission (type-II fluorescence105) for both GO/TiO2 and rGO/TiO2 cases. Such recombination occurs due to the intimate contact between the

components. In the present case the typical distances are \sim 1.608 nm (GO/TiO₂) and \sim 1.156 nm (rGO/TiO₂).²¹² The longer PL decay time of GO/TiO₂ is attributed to the reduced overlap of electron and hole wave functions.¹⁰⁵ In the rGO/TiO₂ case the intimacy between TiO2 and rGO increased and hence the interconnectivity of localized sp² sites and the percentage of zero gap regions is also increased.³⁶ This leads to enhanced charge transfer and consequently better quenching of PL with shortened lifetime.³⁶ As the oxygen content decreases the O2p level will be lifted up causing a red shift in the PL peak of rGO/TiO₂ relative to that of GO/TiO₂. It is notable that the decay times of TiO₂ and rGO or GO were not in the same order of magnitude and as a result, the composite decay time is an integral effect of their individual characteristics. If one has to consider such an argument, then a way needs to be figured out to resolve the decay constant for each of the components. It is interesting to see that the above interpretation combines the effects of sp² cluster localization and the involvement of the O 2p level.

The interface between Fe-doped TiO₂ and GO enables transfer of electrons from the CB of the semiconductor to GO (Fig. 19a) quenching the overall emission. However Fe-doping enables the creation of e-h pairs under visible light illumination. A similar study can be seen on the suppression of PL from TiO₂ under the influence of GO.¹⁷⁹ Furthermore, PL measurements on the GO-ZnS nanocomposite suggest that graphene can be employed to quench the defect level emission.¹⁹¹ However, the details of the defect levels and their passivation mechanism were not suggested. Although it is accepted that the defect levels can be passivated variously with polymers or other inorganic coatings,¹⁹⁸ the energetic location of the defect and its alignment with the bands of GO is a very important factor to consider. We can see other examples in which electron transfer takes place from TiO₂ to GO and rGO.¹⁸² Other inorganic low band gap semiconductors such as Cu₂O showed a similar effect in terms of transfer of photogenerated charge carriers (Cu₂O/PA/rGO and Cu₂O/rGO).¹⁸⁷ Furthermore the transfer of electrons and/or holes takes place across the interface even if more than one semiconductor is present. It is the case with ZnO@ZnS hollow dumbbells-GO composite;²⁹ see the schematic charge transfer process in Fig. 19b.

Fluorescence quenching ability of GO is extended to fluorescein moieties (fluorescein derived silyl ether)²¹³ similar to other complexes with organic dyes.^{136,214} The fluorescence quenching is explained based on the band alignments of fluorescein and GO.²¹⁵ This allows the transfer of photogenerted electrons into the CB of GO (Fig. 20). Besides the regeneration of fluorescein is facilitated by I_3^-/I^- .



Fig. 19 (a) The interface between Fe-doped TiO_2 and GO (b) the band alignment of ZnO@ZnS hollow dumbbells-graphene composites.²⁹ Figures redrawn based on ref. 29 and 181.



Fig. 20 The energy level diagram illustrating the electron transfer process between GO and the fluorescein moiety in fluorescein derived silyl ether. Figure redrawn based on ref. 213.

8. Conclusion and outlook

In this review we have focused on the optical properties of GO and rGO where the fluorescence properties are explored recently. We have discussed the existing mechanisms and pointed out largely ignored issues such as self-rolling, byproduct formation, concentration, dielectric constant etc. It is important to note that the emission properties of GO depend on the synthesis process. The distribution of various oxygen containing functional groups is completely process dependent. Given the vast amount of the literature, a simple and versatile quantification technique is demanding to quantify the functional groups and their spatial distribution. These two factors play a crucial role in determining the emission properties. Generally, an ensemble of GO sheets is considered for spectral analysis. This ensemble includes various shapes, sizes which are crucial parameters to be evaluated. In case if the sample contains a class of material at low concentration with high QY, then we may observe a predominant emission peak. While that peak wavelength will be interpreted against the majority distribution. In order to avoid such discrepancies one needs to consider studying a single sheet of GO and its fluorescence. Notably, the degree of oxidation and reduction can be employed to tune the emission properties of GO and rGO while a precise control on the relative densities of functional groups still needs to be achieved. For example, during the reduction some of the functional groups are reduced faster than others, although the optical band gap is tunable. The detailed understanding of nanometer- to sub-nanometer-scale structures of GO and rGO can perhaps show new directions for the interpretation of their fluorescence. The plus point is that the oxygen containing functional group on GO and rGO enables further functionalization with other materials. Moreover, it is soluble in a variety of solvents and hence subsequent incorporation into composites is an easy task.

Fluorescence from GO opens new and exciting opportunities for exploration of photonic devices such as LEDs, photodetectors, photovoltaics *etc.* However, photodetector studies should focus on wavelength selectivity.¹⁸ Such studies not only give further insight into the energy levels of GO but also shed some light on the fluorescence mechanism in an indirect fashion. The fluorescence from GO and rGO depends on various factors. Despite this, molecular sensing with rGO is quite promising, where its sensitivity to certain chemicals and relatively higher signal-to-noise ratio are worth mentioning. Although there are some *in vivo* studies, cell imaging *etc.*, for practical applications the selectivity to some ions or molecules and recycling require further studies.

The characteristics of GO and rGO are not only determined by the level of oxidation, but also strongly influenced by the distribution of conjugated carbons, holes, vacancies, folds, wrinkles, interfaces of sheets etc. Furthermore one should note the differences in the emission depending on the synthesis process.^{15,36,58} Strong localization of sp² clusters and involvement of oxygen functional groups in the fluorescence of GO or rGO deserves further attention. If the oxygen functional groups have to be eliminated from the luminescence mechanism, then the sp² clusters should be localized in a matrix that doesn't contain any oxygen or related functional groups. For example, a complete substitution of oxygen with a suitable element while retaining the lattice constant of oxidized (modified) graphene can be an example target material. Also the average sheet dimensions should not be modified in the process of substitution. This is in clear contrast to a simple reduction of GO. The unique 2D lattices of GO and rGO provide an exciting platform in which various applications and fundamental interests are involved in engineering, physics, chemistry, biology and materials science.

Abbreviations

Materials

Materials	
\mathbf{P}^{-}	Negatively charged porphyrin
\mathbf{P}^+	Positively charged porphyrin
CNT	Carbon nanotube
Au NPs	Au nanoparticles
PEDOT:PSS	Poly(3,4-ethylenedioxythiophene) polystyrene
	sulfonate
Poly-TPD	Poly(<i>N</i> , <i>N</i> '-bis(4-butylphenyl)- <i>N</i> , <i>N</i> '-bis(phenyl)
	benzidine)
SLG	Single layer graphene
PEG	Polyethylene glycol
PA	<i>n</i> -Propylamine
P3HT	Poly(3-hexylthiophene-2,5-diyl)
GO QDs	Graphene oxide quantum dots
NPs	Nanoparticles
MB	Methylene blue
Rb	Riboflavin
CMG	Chemically modified graphene
QDs	Quantum dots
FTO	Fluorene doped tin oxide
PPV	Poly(<i>p</i> -phenylenevinylene)
CNT	Carbon nanotube
SWNT	Single walled carbon nanotube
PANI	Polyaniline

Other symbols/abbreviations

Near-infrared
Heterojunctions
Forward bias
Intra-molecular proton transfer
Quantum yield

RT	Room temperature
$E_{\rm v}$, VB	Valance band
$E_{\rm c}$, CB	Conduction band
VBM	Valance band maximum
$\lambda_{\rm em}$	Emission wavelength
η	Efficiency
$J_{ m sc}$	Short-circuit current density
J_0	Saturation current
V _{oc}	Open-circuit voltage
FF	Fill factor
χ	The electron affinity
PCE	Power conversion efficiency
DFT	Density functional theory
Vo	Oxygen vacancy
Zn _i s	Zinc interstitial
IOT	Indirect optical transitions
PR	Photoresponse
MO	Molecular orbital
PDOS	Partial density of state
EL	Electroluminescence
FET	Field-effect transistors
$E_{\rm F}$	Fermi level
CBM	Conduction band minimum
LUMO	Lowest unoccupied molecular orbital
НОМО	Highest occupied molecular orbital

Instrumentation

CLSM	Confocal laser scanning microscopic
TEM	Transmission electron microscopy
DLS	Dynamic light scattering
EELS	Electron energy loss spectroscopy
AFM	Atomic force microscopy
CV	Cyclic voltammetry
PLE	Photoluminescence excitation
PDS	Photothermal deflection spectroscopy

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